



Attorney Docket No. UMC-96-279 CON
Client Matter No. 81848.0016.001
Confirmation No. 4793

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Chih-Chien LIU, et al

Serial No. 09/546,174

Filed: April 11, 2000

For: HIGH DENSITY PLASMA CHEMICAL
VAPOR DEPOSITION PROCESS

Examiner: R. SERGENT

Art Unit: 1711

#9) Ext
3/26/02

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PETITION FOR 5-MONTH EXTENSION

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

A Communication was mailed September 12, 2001, setting a one-month period, to October 12, 2001, in which to supplement a non-responsive Amendment filed July 2, 2001. On November 26, 2001, a Petition for 2-Month Extension was filed and the \$400 fee paid, to extend the period for response to December 12, 2001.

The Application hereby petitions for a 5-month extension, thereby extending the period for response to March 12, 2002. The enclosed check for \$1,742.00 includes \$1,560 as the fee associated with this petition (the 5-month fee of \$1,960 less \$400 previously paid). Should any additional fees be required, please charge Deposit Account No. 50-1123.

Respectfully submitted,

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March 11, 2002

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